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 APPLICATION NO.
 FILING DATE
 FIRST NAMED INVENTOR
 ATTORNEY DOCKET NO.

 09/476,961
 01/03/00
 YU
 B
 39153/223-(E

MM92/0424

EXAMINER

JOSEPH N ZIEBERT FOLEY & LARDNER FIRSTAR CENTER 777 E AST WISCONSIN AVENUE MILWAUKEE WI 53202-5367

ART UNIT PAPER NUMBER
2815

WARREN. M

'DATE MAILED:

04/24/01

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

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÷*	Offic Action Summary	09/476,961	YU, BIN
		Examiner	Art Unit
		Matthew E. Warren	2815
	Th MAILING DATE of this communication appe	ears on the cover sheet with the c	orrespondence address
Period fo		VIO OCT TO EVDIDE 4 MONTH	(C) EDOM
THE N - Exten after 5 - If the - If NO - Failur - Any fr	ORTENED STATUTORY PERIOD FOR REPL MAILING DATE OF THIS COMMUNICATION. Issions of time may be available under the provisions of 37 CFR 1.1 SIX (6) MONTHS from the mailing date of this communication. Period for reply specified above is less than thirty (30) days, a repleperiod for reply is specified above, the maximum statutory period re to reply within the set or extended period for reply will, by statute eply received by the Office later than three months after the mailined patent term adjustment. See 37 CFR 1.704(b).	I36 (a). In no event, however, may a reply be to ly within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from the cause the application to become ABANDONE	mely filed ys will be considered timely. the mailing date of this communication. ED (35 U.S.C. § 133).
1)⊠	Responsive to communication(s) filed on 03	January 2000 .	
2a)□	•	nis action is non-final.	
3)	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.		
Dispositi	on of Claims		
4)⊠	Claim(s) <u>1-20</u> is/are pending in the application.		
	4a) Of the above claim(s) is/are withdrawn from consideration.		
5) 🗌	Claim(s) is/are allowed.		
6)	Claim(s) is/are rejected.		
7)	Claim(s) is/are objected to.		
8)⊠	Claims $\underline{1-20}$ are subject to restriction and/or	election requirement.	
Applicati	ion Papers		
9)	The specification is objected to by the Examir	ner.	
10)	The drawing(s) filed on is/are objected to by the Examiner.		
11)] The proposed drawing correction filed on is: a) ☐ approved b) ☐ disapproved.		
12)	The oath or declaration is objected to by the B	Examiner.	
Priority :	under 35 U.S.C. \$ 119		
_	Acknowledgment is made of a claim for foreig	gn priority under 35 U.S.C. \$ 119	(a)-(d) or (f).
	☐ All b)☐ Some * c)☐ None of:	•	
a,	1. Certified copies of the priority documents have been received.		
l .	2. Certified copies of the priority documer		tion No
	3 ☐ Copies of the certified copies of the pri	ority documents have been recei	
	application from the International B See the attached detailed Office action for a lis	Bureau (PCT Rule 17.2(a)).	
14)[_]	Ackilowieugement is made of a diam for don	notice pricing allact de dielo.	• •
Attachmer	nt(s)		
	tice of References Cited (PTO-892)		nary (PTO-413) Paper No(s)
16) 🔲 No	tice of Draftsperson's Patent Drawing Review (PTO-948) promation Disclosure Statement(s) (PTO-1449) Paper No(s	<i>'</i> =	nal Patent Application (PTO-152)

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DETAILED ACTION

Election/Restrictions

Restriction to one of the following inventions is required under 35 U.S.C. 121:

- Claims 18-20, drawn to semiconductor device, classified in class 257, subclass 288.
- II. Claims 1-17, drawn to a method of making a semiconductor, classified in class 438, subclass 1+.

The inventions are distinct, each from the other because of the following reasons:

Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of the following can be shown: (1) that the process as claimed can be used to make other and materially different product or (2) that the product as claimed can be made by another and materially different process (MPEP § 806.05(f)). In the instant case the process of forming deep source and drain regions with dopants of a first conductivity type could also be used to form source and drain regions near a trench for a trenched gate semiconductor device.

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, restriction for examination purposes as indicated is proper.

Applicant is advised that the reply to this requirement to be complete must include an election of the invention to be examined even though the requirement be traversed (37 CFR 1.143).

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Matthew E. Warren whose telephone number is (703) 305-0760. The examiner can normally be reached on Mon-Thurs, and alternating Fri, 9:00-5:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Eddie Lee can be reached on (703) 308-1690. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 305-3432 for regular communications and (703) 308-7722 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

MEW

April 21, 2001

EDDIE LEE

SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800